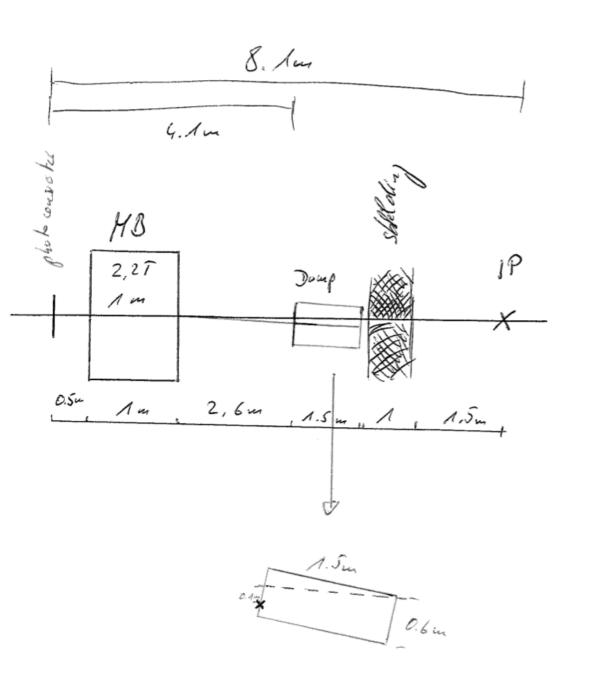
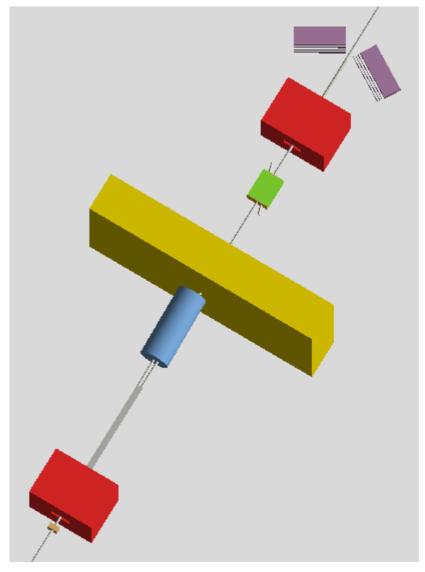
LUXE Background Study in Simulation

Oleksandr Borysov

LUXE Meeting July 23, 2019

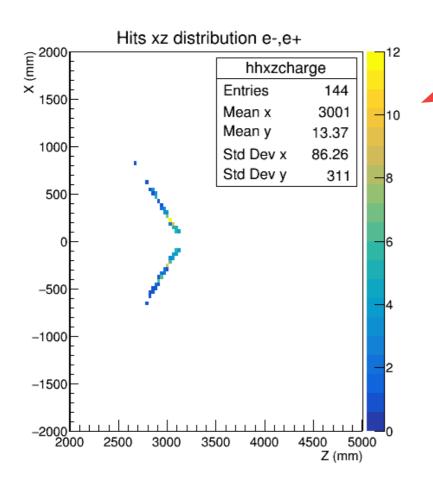
Sketch and Geant4

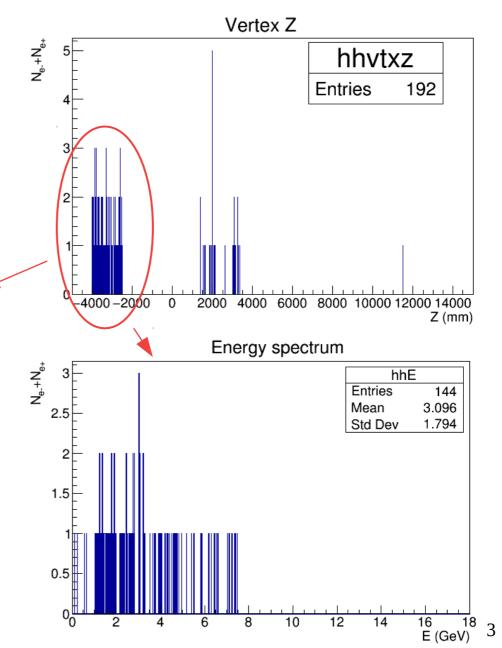




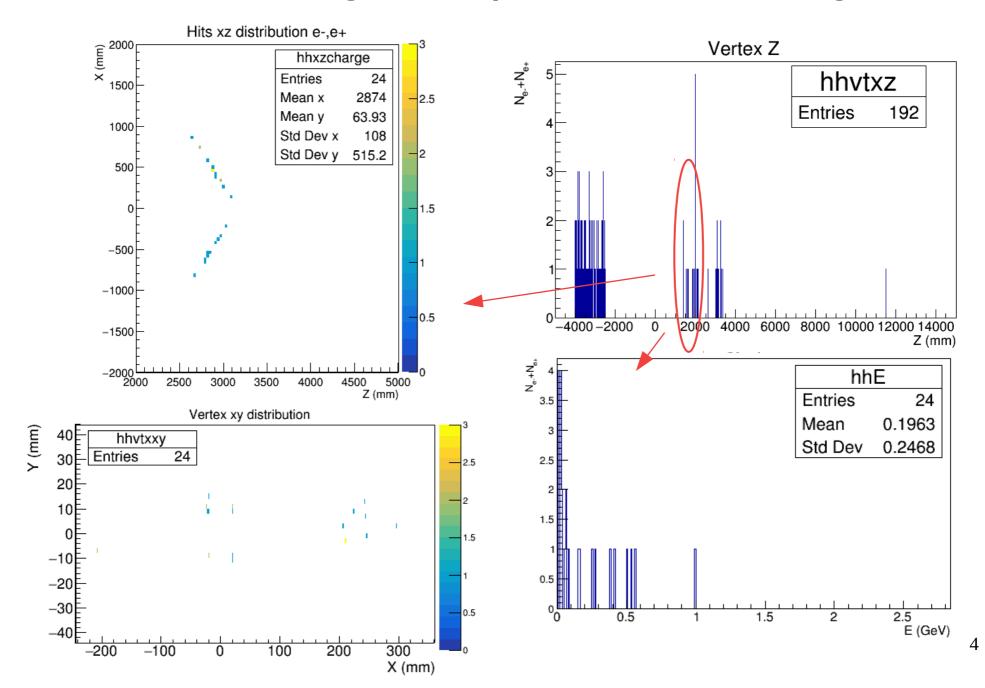
Hits with origin in collimator

10.72 M electrons of 17.5 GeV with 35 µm tungsten target were simulated

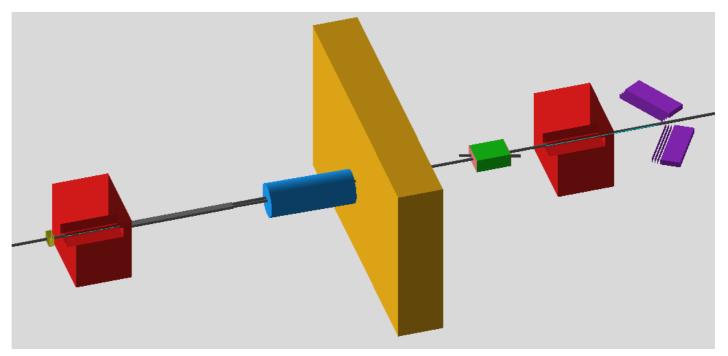




Hits with origin in spectrometer magnet



Magnet after beam dump



Magnet:

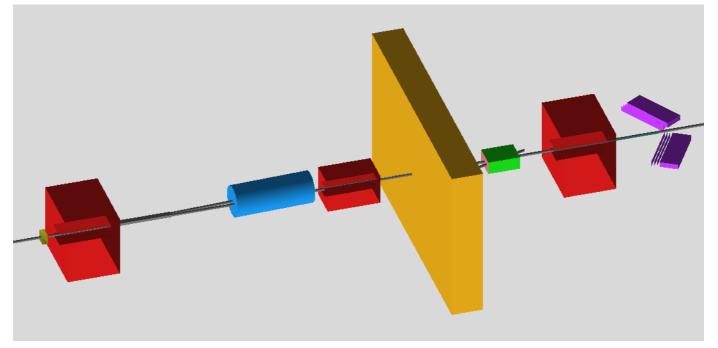
Length: 1 m;

• Drift: 0.7 m;

• y = 6.3 cm, for 8 GeV

Distance

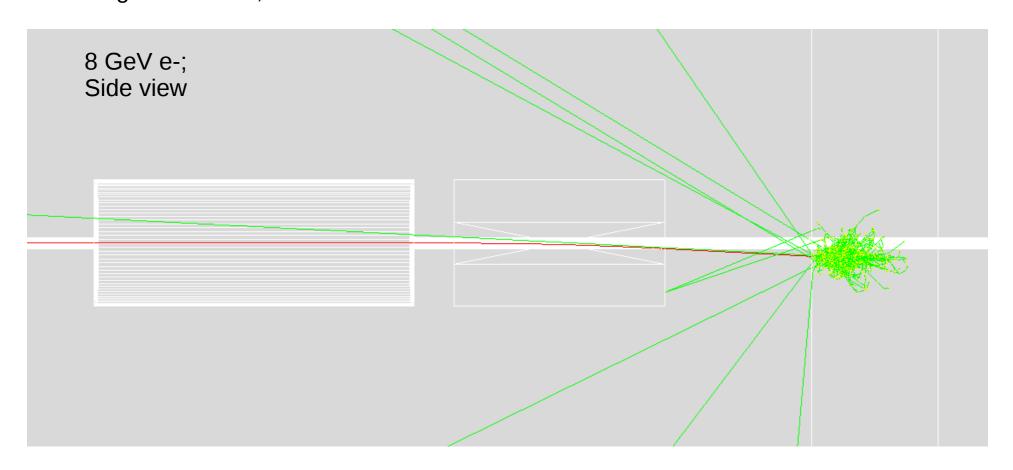
Target – IP: 9 m.



Dipole after dump

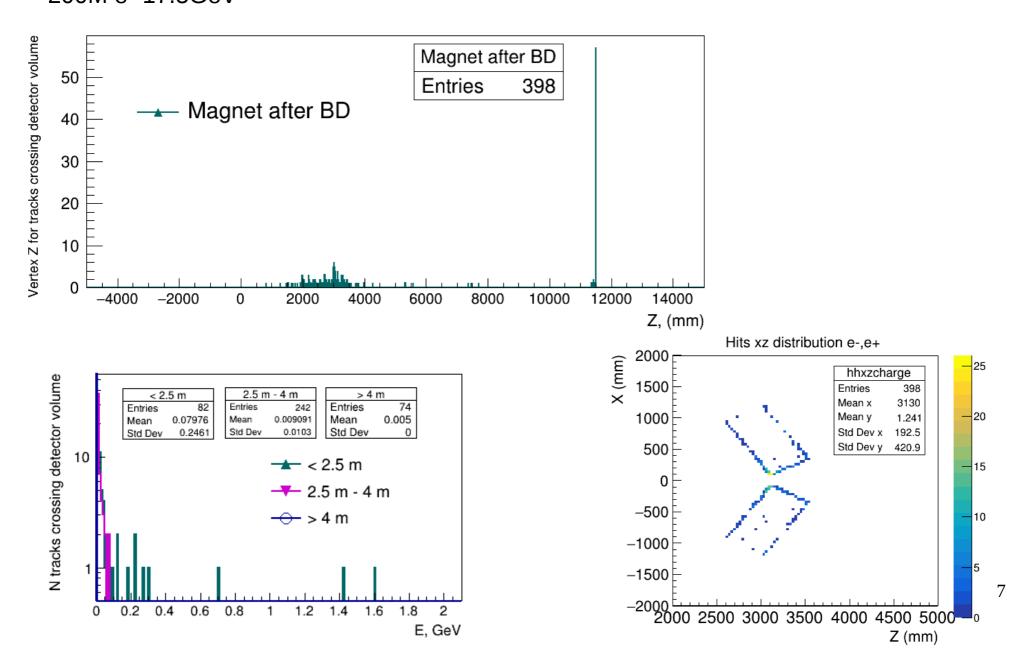
Field: 1.4 T;

Magnet length: 1m; Drift length: 0.7m;

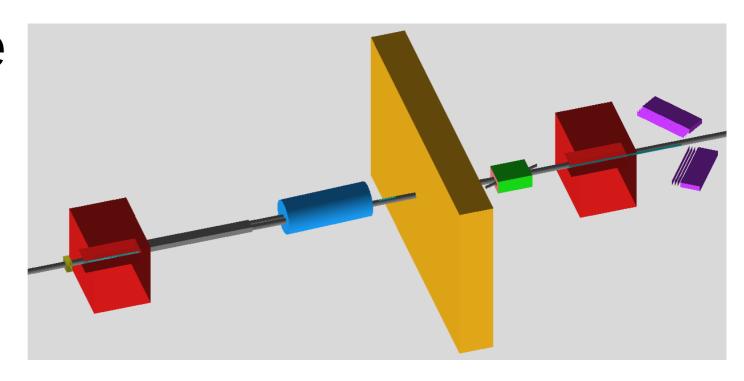


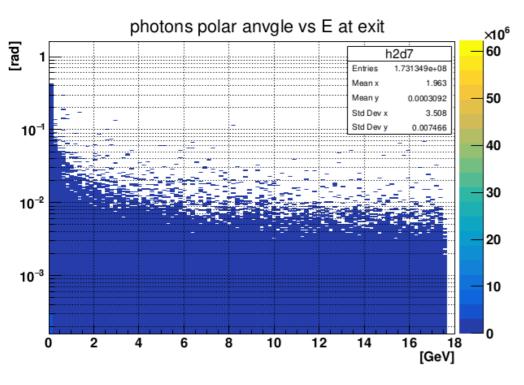
Dipole after dump

Field: 1.4 T; Magnet length: 1m; Drift length: 0.7m; 200M e- 17.5GeV



Beam Pipe D = 10 cm

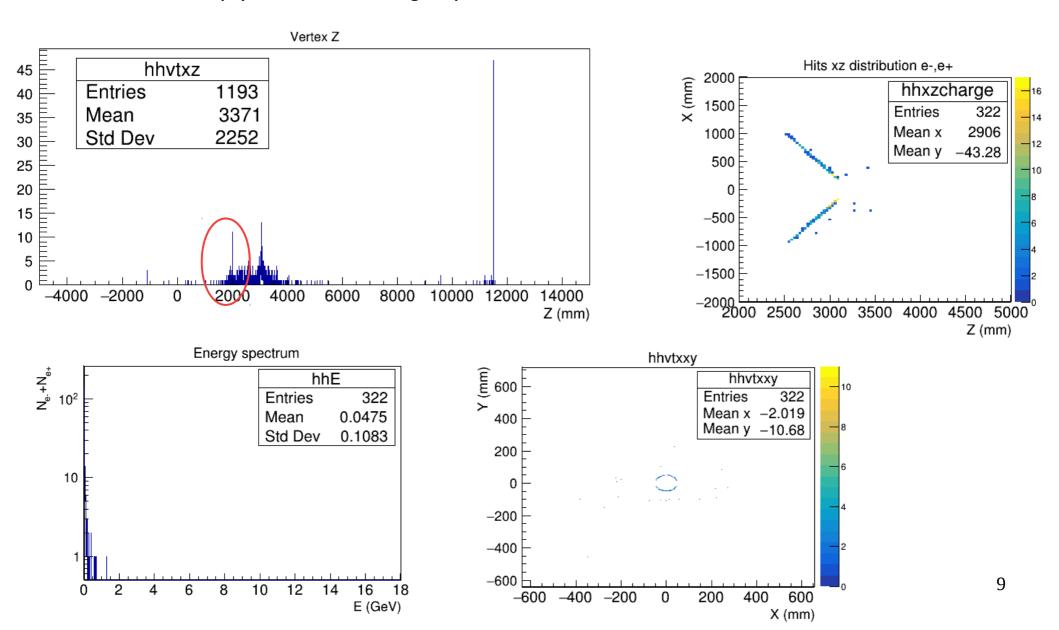




Beam Pipe D = 10 cm. Vertexes of the e+, e- tracks entering the detector volume.

300M e-;

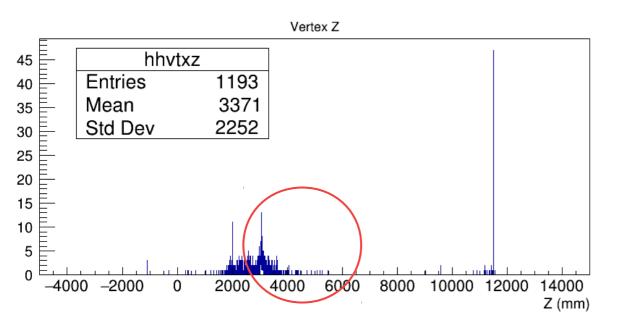
1m < Z < 2.5m; (Spectrometer magnet)

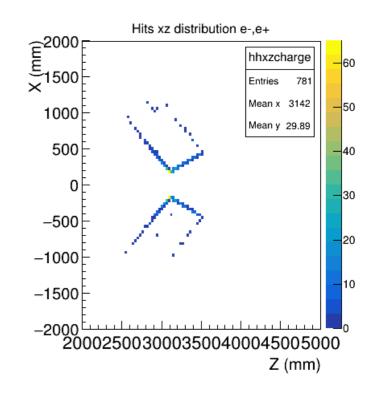


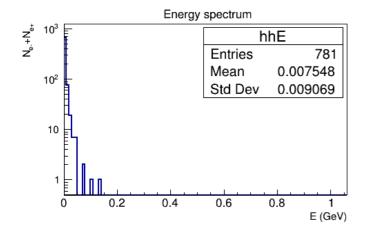
Beam Pipe D = 10 cm. Vertexes of the e+, e- tracks entering the detector volume.

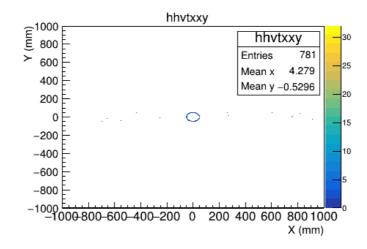
300M e-;

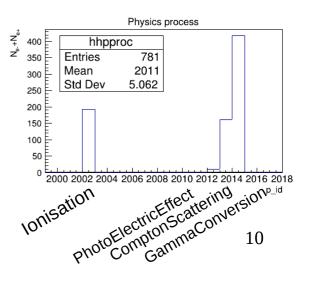
2.5m < Z < 6m; (detectors and beam pipe)







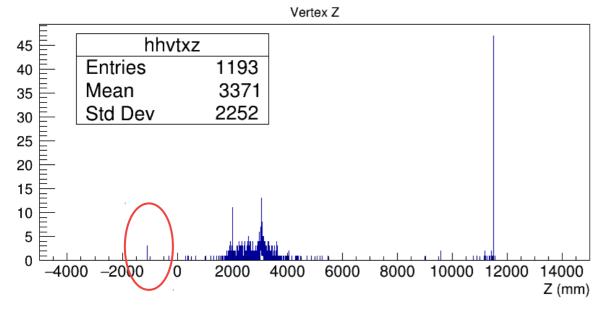


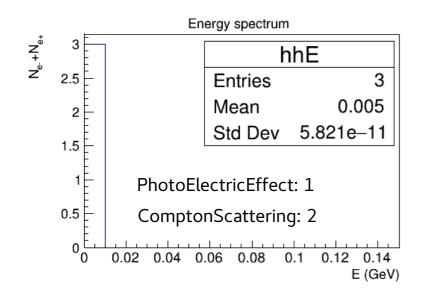


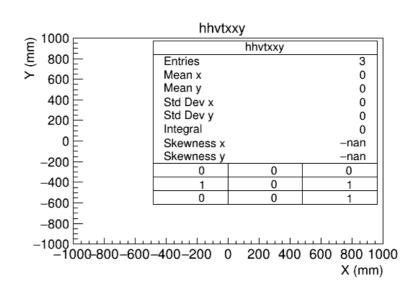
Beam Pipe D = 10 cm. Vertexes of the e+, e- tracks entering the detector volume.

300M e-;

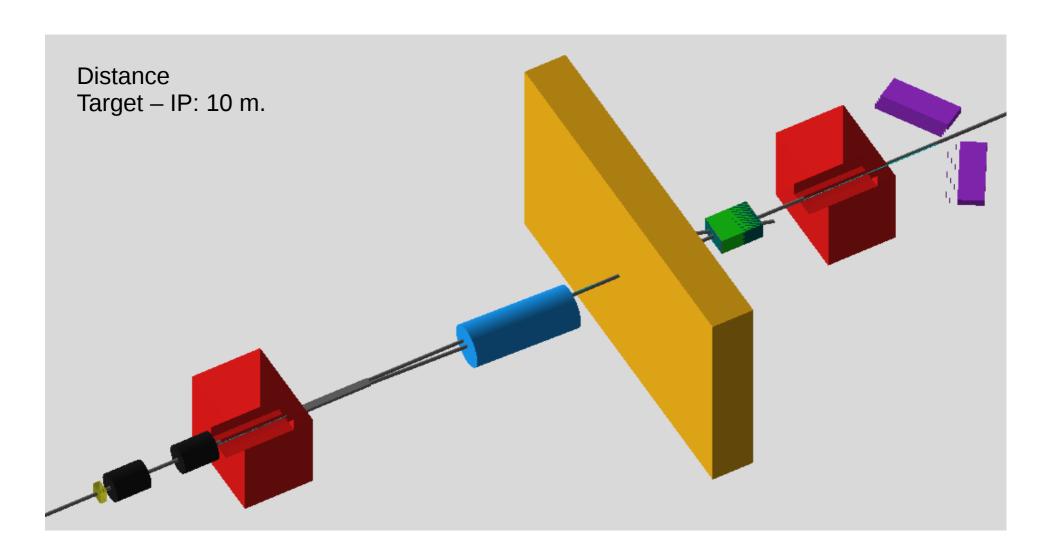
-1.2m < Z < -1m; (Shielding)







Two lead collimators



Summary and Plans

- Number of electrons and positrons produced in a collimator constitute substantial background for BPPP study.
- Installing magnet after the collimator helps to eliminate the background.
- Wide beam pipe D=10cm shows significant reduction in backgrounds.
- Electrons and positrons produced in the area of spectrometer magnet can be identified and rejected
 - by the tracker in case the vertex is in metal part far from beam pipe;
 - by calorimeter for those of low energy generated close to the exit of the magnet.
- Run simulation with two collimators between the target and dump magnet, similar to the geometry simulated in Fluka by Gianluca.
- Tune geometrical parameters of the setup in accordance with real technical requirements.